PATENT

Attorney Docket No.: AMAT/6339/CMP/CMP/RKK

Express Mail No. EL913563591US

ABSTRACT OF THE DISCLOSURE

Systems and methods for detecting the endpoint of a polishing step. In general, an electropolishing system is provided with a power supply configured to deliver a current through an electrolytic solution. Signal characteristics of the signal provided by the power supply are monitored to determine a polishing endpoint. Illustratively, the monitored signal characteristics include current and voltage.